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Complete if Known Substitute for form 1449A/PTO TBA **Application Number INFORMATION DISCLOSURE** September 9, 2003 **Filing Date** Patrick M. Martin STATEMENT BY APPLICANT First Named Inventor **TBA** Art Unit (use as many sheets as necessary) **TBA Examiner Name** of Attorney Docket Number 67493/63 2 Sheet

	U.S. PATENT DOCUMENTS							
Examiner Initials		Document Number Number - Kind Code <sup>2</sup> (if known	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear			
136	1	us- 4,178,403	12-11-1979	Sakurai et al.				
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Examiner Inklals	Cite No.1	Foreign Patent Document  Country Code 3 - Number 4 - Kind Code 4 (# known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Te				

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PTO/SB/08B (10-01)

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Substitute for	or form 1449B/PTC	<b>5</b>		Complete if Known			
INFOR	A TION			Application Number	TBA		
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STATI	EMENT P	X V	PPLICANT	First Named Inventor	Patrick M. Martin		
O.A.	-141-141 -		LIOAN	Group Art Unit	TBA		
	(use as many si	heets as	s necessary)	Examiner Name	TBA		
Sheet	2	of	2	Attorney Docket Number	67493/63		

		OTHER PRIOR ART NON PATENT LITERATURE DOCUMENTS					
Examiner Initials	Cite No. 1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published					
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	19	T. EBIHARA, T. OGA, P.D. RHYINS, M. SWEIS, P.M. MARTIN, "150-nm dense/isolated contact hole study with Canon IDEAL technique", SPIE Proceeding 4562-119.					
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	25	T. TERASAWA, N. HASEGAWA, A. IMAI and S. OKAZAKI, "Analysis of Nonplanar Topography Effects of Phase Shift Masks on Imaging Characteristics", Japanese J. Appl. Phys. 34, 6578-6583 (1995).					
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Signature		- Coamaro	Considered		91	00

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